

### **REMARKS**

Claims 1-7, 10, and 11 are now pending in the application. Claims 8, 9 and 12-20 are now cancelled. Claims 1, 7, 10, and 11 are now amended. The claim amendments are fully supported by the application as filed and do not present new subject matter. The Examiner is respectfully requested to reconsider and withdraw the rejections in view of the amendments and remarks contained herein.

### **ELECTION/RESTRICTION REQUIREMENT**

Claims 8, 9, and 12-20 stand withdrawn as allegedly being directed to a non-elected invention. Applicant submits that consideration of all the claims as filed will not place an undue burden on the Examiner. However, in order to expedite prosecution of this application, Applicant now cancels withdrawn Claims 8, 9, and 12-20.

### **SPECIFICATION**

The title stands objected to as allegedly not being descriptive of the invention. Applicant now amends the title to recite: "METHOD OF FORMING A FILM PATTERN ON A SUBSTRATE BY ARRANGING DROPLETS OF LIQUID MATERIAL ON THE SUBSTRATE." Applicant submits that the new title is sufficiently descriptive of the invention. Therefore, Applicant respectfully requests reconsideration and withdrawal of this objection to the title.

### REJECTION UNDER 35 U.S.C. § 102

Claims 1-7 and 10-11 stand rejected under 35 U.S.C. § 102(e) as being anticipated by Banno et al. (U.S. Pat. No. 6,761,925). Claims 1-7, 10 and 11 stand rejected under 35 U.S.C. § 102(b) as being anticipated by Shigeoka (JP 09-245,698). These rejections are respectfully traversed.

Amended Claims 1, 7, 10, and 11 recite, in part, "wherein a periphery portion of the film patterns is formed before an interior portion of the film patterns is formed."

The Banno et al. reference appears to disclose, with reference to Figures 31A-33D, a method of forming elements on a substrate through droplet deposition. However, the Banno et al. reference fails to disclose or suggest forming a periphery of the elements before forming an interior portion of the elements.

The Shigeoka reference appears to disclose, with reference to Figures 1-3, forming a conductive film 4 having an electron-emitting part 5 by droplet deposition. The Shigeoka reference fails to disclose or suggest depositing the droplets such that a periphery portion of the conductive film and/or the electron-emitting part is formed before an interior portion is formed.

The Banno et al. and the Shigeoka references each fail to disclose or suggest "wherein a periphery portion of the film patterns is formed before an interior portion of the film patterns is formed," as set forth in amended independent Claims 1, 7, 10, and 11. Thus, both the Banno et al. and the Shigeoka references fail to disclose or suggest each and every feature of amended Claims 1, 7, 10, and 11. Therefore, the cited art fails to anticipate or render obvious amended Claims 1, 7, 10, and 11, as well as those

claims dependent therefrom. Applicant respectfully requests reconsideration and withdrawal of the Section 102 rejections.

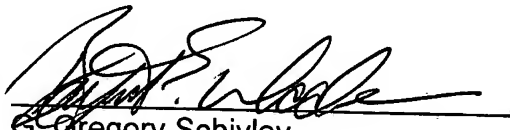
**CONCLUSION**

It is believed that all of the stated grounds of rejection have been properly traversed, accommodated, or rendered moot. Applicant therefore respectfully requests that the Examiner reconsider and withdraw all presently outstanding rejections. It is believed that a full and complete response has been made to the outstanding Office Action and the present application is in condition for allowance. Thus, prompt and favorable consideration of this amendment is respectfully requested. If the Examiner believes that personal communication will expedite prosecution of this application, the Examiner is invited to telephone the undersigned at (248) 641-1600.

Respectfully submitted,

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